

					Search Text	DBs	Time Stamp	Comments	Errors
Type	L #	Hit #							
1	IS&R	L86	368		((359/290,291,295,298,302,311) or (73/720,721,722,723,715) or (216/2) or (438/53)).CCLS.	USP AT; US- PGP UB	2003 /10/ 22 08:5 3		0
2	BRS	L9	429		8 and (mems or micro-electromechanic\$4 or (micro adj electr\$4 adj mechanic\$4))	USP AT; US- PGP UB	2003 /10/ 22 08:5 4		0
3	BRS	L10	389		9 and (sacrificial\$3 or psg or (phosposilicate adj glass) or polysilicon or silicon)	USP AT; US- PGP UB	2003 /10/ 22 08:5 5		0
4	BRS	L11	108		10 and transduc\$4	USP AT; US- PGP UB	2003 /10/ 22 08:5 5		0
5	BRS	L12	77		11 and (diaphragm or (silicon adj1 nitride) or (silicon adj1 dioxide))	USP AT; US- PGP UB	2003 /10/ 22 08:5 6		0
6	BRS	L13	67		12 and ((remov\$4 or etch\$4) with (sacrificial\$3 or psg or (phosposilicate adj glass) or polysilicon or silicon))	USP AT; US- PGP UB	2003 /10/ 22 08:5 6		0
7	BRS	L15	63		12 and ((remov\$4 or etch\$4) near3 (sacrificial\$3 or psg or (phosposilicate adj glass) or polysilicon or silicon))	USP AT; US- PGP UB	2003 /10/ 22 08:5 6		0
8	BRS	L14	4		13 and ((diaphragm or (silicon adj1 nitride) or (silicon adj1 dioxide)) with suspend\$4)	USP AT; US- PGP UB	2003 /10/ 22 08:5 7		0

					Search Text	DBs	Time Stamp	Errors	Corr. Errors	Comm. Errors	Corr. D errors	Corr. E errors
Type	L #	Hit s										
9	BRS	L16	11	15	and void\$3	USP AT; US- PGP UB	2003 /10/ 22 08:5 7				0	

					Search Text	DBs	Time Stamp	Comments	Corr. Defs	Error Instr.
Type	L #	Hit #								
1	BRS	L1	911	6	(mems or (micro-electromechanic\$4) or (micro adj1 electr\$4 adj1 mechanic\$4))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/10/22 08:32			0
2	BRS	L2	573	0	1 and (sacrificial\$3 or psg or (phosposilicate adj1 glass) or polysilicon or silicon)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/10/22 08:33			0
3	BRS	L3	269	2	2 and (diaphragm or (silicon adj1 nitride) or (silicon adj1 dioxide))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/10/22 08:36			0
4	BRS	L4	781	3	3 and transduc\$4	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/10/22 08:35			0
5	BRS	L5	612	4	4 and ((remov\$4 or etch\$4) with (sacrificial\$3 or psg or (phosposilicate adj1 glass) or polysilicon or silicon))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/10/22 08:35			0
6	BRS	L6	534	5	4 and ((remov\$4 or etch\$4) near3 (sacrificial\$3 or psg or (phosposilicate adj1 glass) or polysilicon or silicon))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/10/22 08:35			0
7	BRS	L7	28	6	6 and ((diaphragm or (silicon adj1 nitride) or (silicon adj1 dioxide)) with suspend\$4)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/10/22 08:36			0